



IFW

Docket No.: 8734.247.00
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:
Seok Woo LEE

Customer No.: 30827

Application No.: 10/695,897

Confirmation No. 5713

Filed: October 30, 2003

Art Unit: 2822

For: METHOD OF FORMING POLYSILICON
THIN FILM TRANSISTOR

Examiner: Maria F. Guerrero

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

In response to the Non-Final Office Action dated June 16, 2005 Applicant hereby requests entry of the following amendments.

INTRODUCTORY COMMENTS

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims which begins on page 5 of this paper.

Remarks begin on page 9 of this paper.